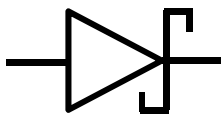


Session 5: MS junction

**Solid State Devices:**

1

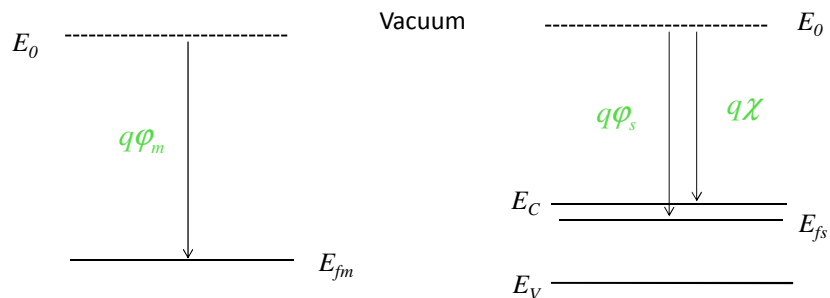


MS Junctions: Electrostatics & IV curve

**The Junction**

2

## MS Junctions - Before being joined

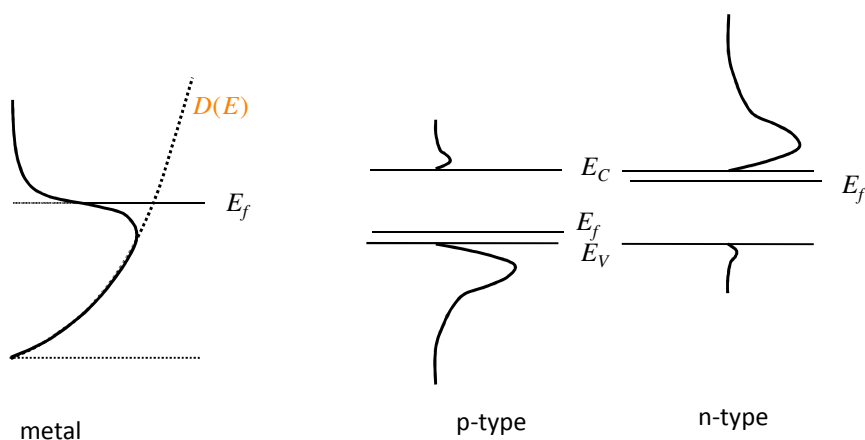


$q\phi_m$  work function (4.75eV for Au)

$q\chi$  electron affinity(4eV for Si)

3

## Reminder



4

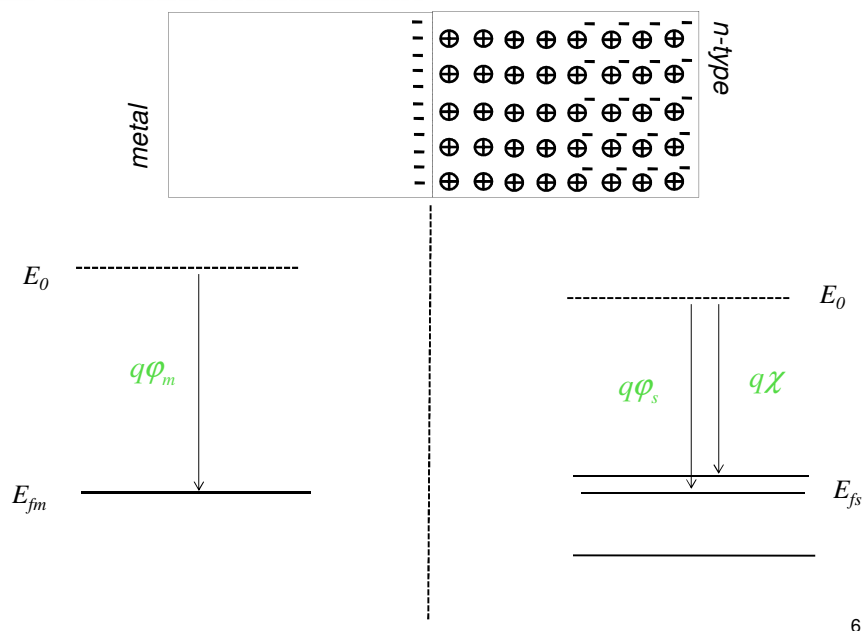
## Plotting Energy Band for MS Junction

Step by step:

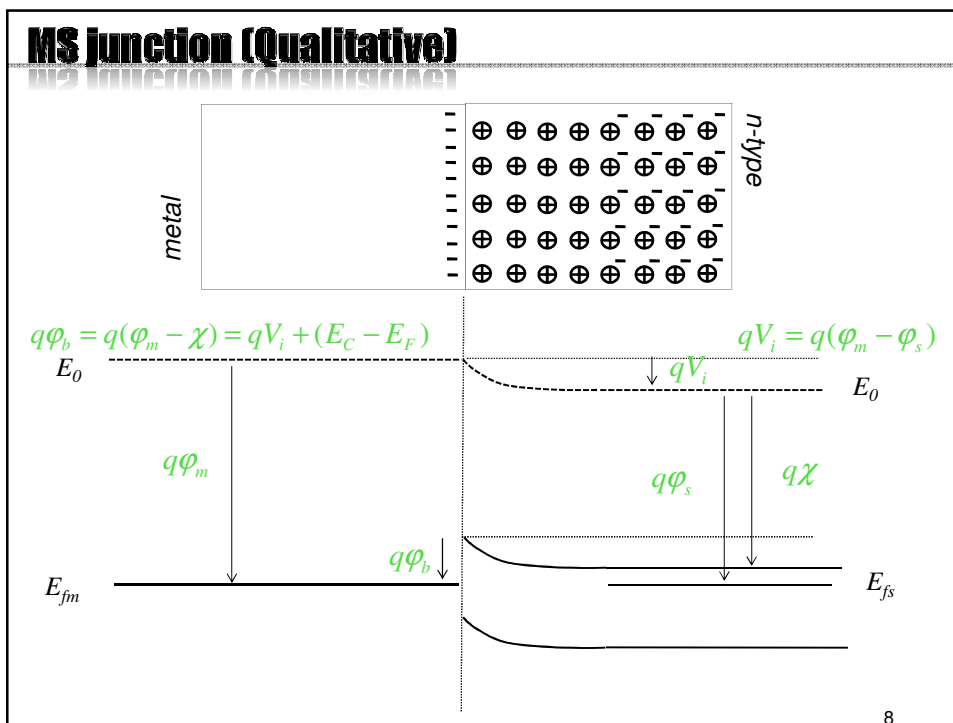
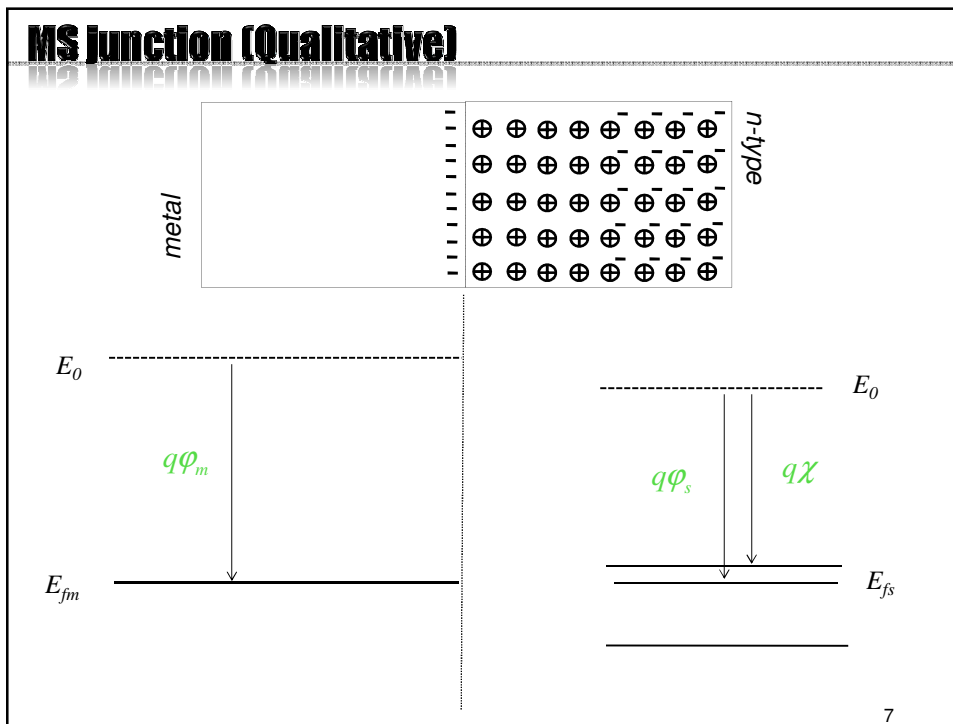
1. Vacuum energy ( $E_0$ ) is continuous.
2.  $E_G$  and  $\chi$  are intrinsic properties of materials and should remain constant. (which means  $E_C$ ,  $E_V$ , and  $E_0$  are all parallel)
3. At equilibrium  $E_f$  is constant while by applying voltage  $\Delta E_f = -qV$ .

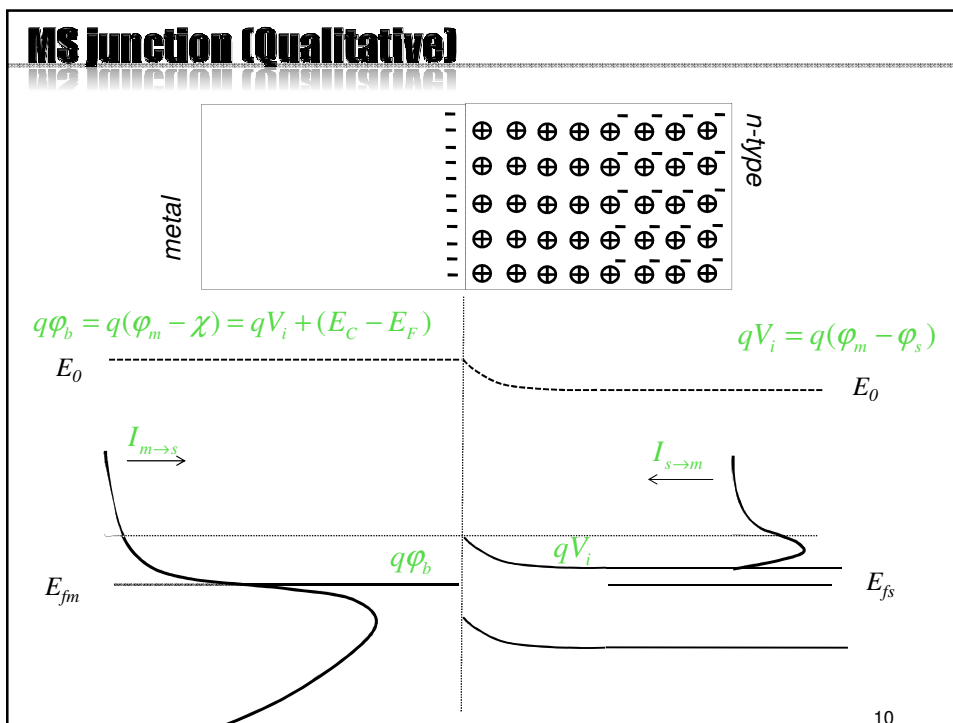
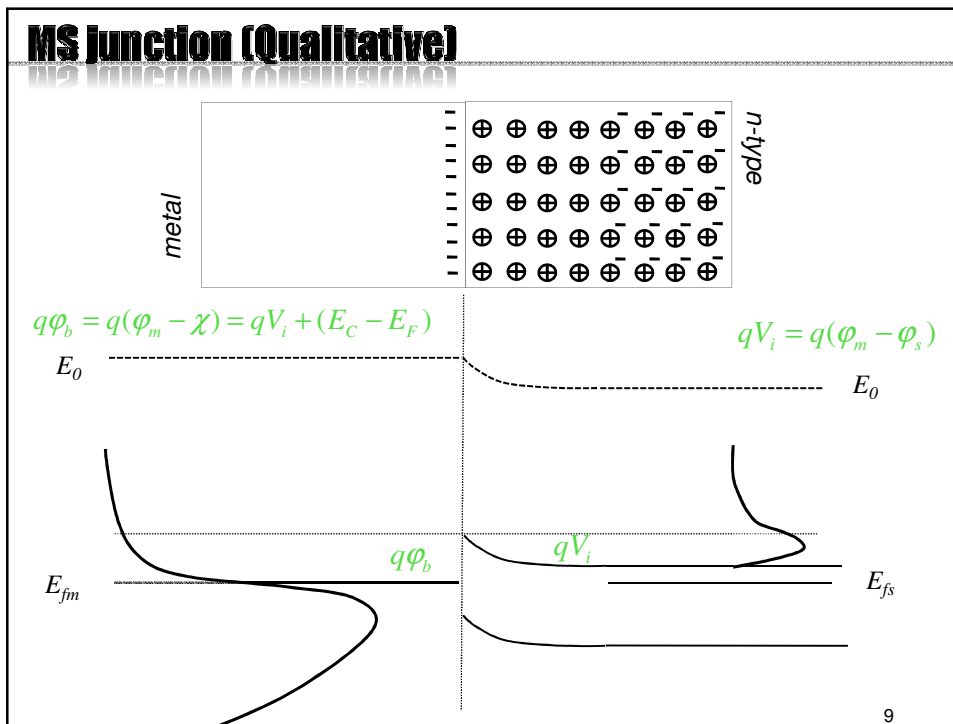
5

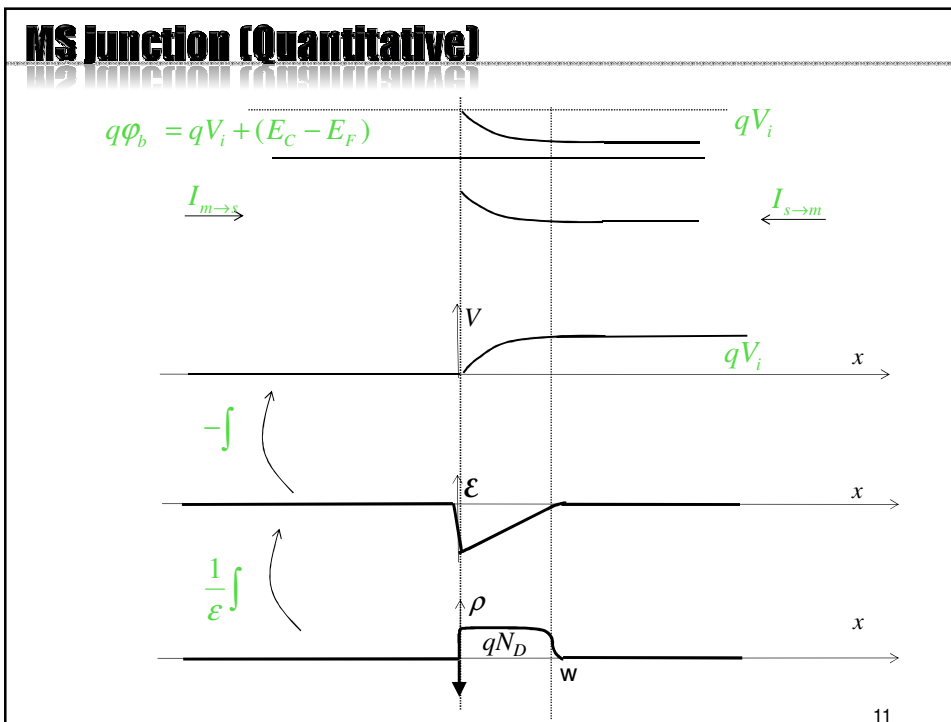
## MS Junction (Qualitative)



6







### MS Junction (Schottky Effect)

$$\mathcal{E}(0) = -qN_D w / \epsilon$$

$$V_i = \frac{1}{2} w \mathcal{E}(0) = qN_D w^2 / 2\epsilon$$

$$w = \sqrt{\frac{2\epsilon}{qN_D} (V_i - V_a)} \quad \mathcal{E}(0) = -\sqrt{\frac{2qN_D}{\epsilon} (V_i - V_a)}$$

as  $qV_i = q(\phi_m - \phi_s)$  seems that  $V_i$  is independent of the applied voltage

But it is not! This is known as "Schottky Effect." This will lower  $V_i$  ( $\phi_b$ ) a little bit.

Image method

The diagram shows a metal surface with a positive charge  $\oplus$  at a distance  $x$  from the surface. An image charge  $\ominus$  is induced in the metal. The electric field  $F(x)$  is given by  $F(x) = \frac{-q^2}{16\pi\epsilon x^2}$ , leading to the potential  $\phi(x) = -qV(x) = \frac{-q^2}{16\pi x}$ .

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### MS Junction, I-V Curve

$\phi'_b = \phi_b - \Delta\phi_b$   
 $\Delta\phi_b = \sqrt[4]{\frac{q^3 N_D}{8\pi^2 \epsilon^2} (V_i - V_a)}$   
 $I_{m \rightarrow s} = AR^* T^2 e^{-q(\phi'_b - V_a)/kT}$   
 $I_{s \rightarrow m} = -AR^* T^2 e^{-q\phi'_b/kT}$   
 $I = I_{m \rightarrow s} - I_{s \rightarrow m} = AR^* T^2 e^{-q\phi'_b/kT} [e^{qV_a/kT} - 1] = I_s (e^{qV_a/kT} - 1)$

$I_{s-shottky} \approx 100 - 1000 I_{0-pn}$

0.3 ~ 0.4V      0.7V

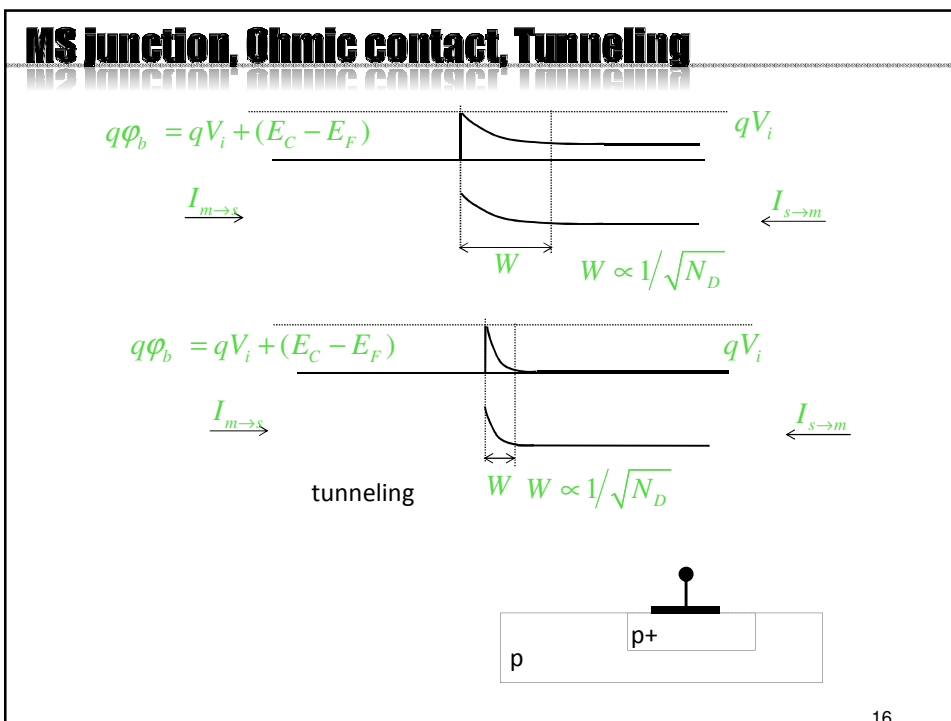
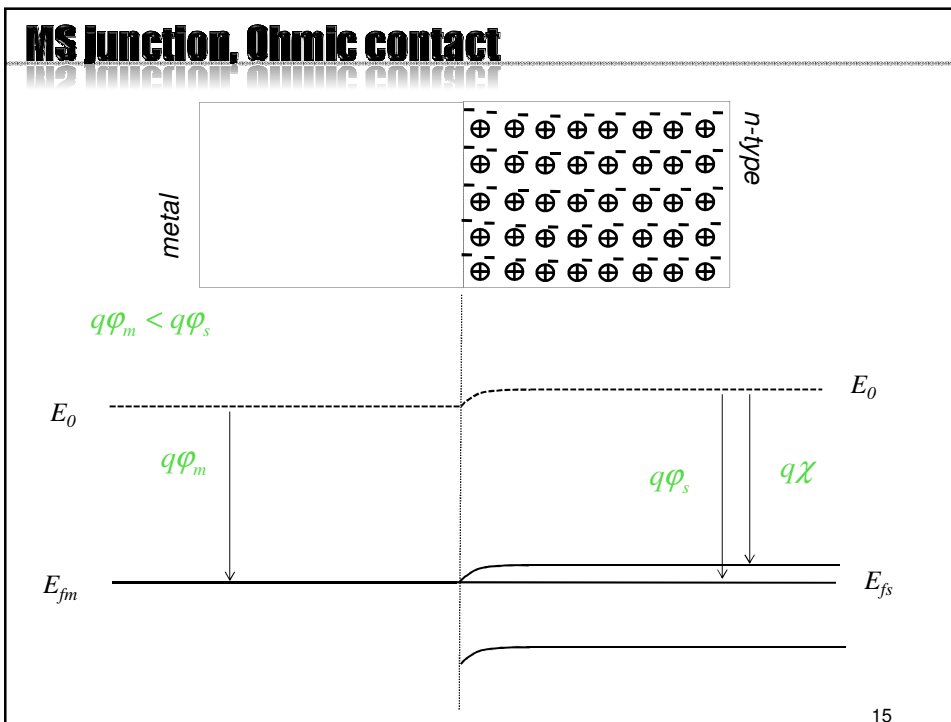
13

### MS Junction, Ohmic contact


metal      n-type

$E_0$        $E_0$   
 $q\phi_m$        $q\phi_s$        $q\chi$   
 $E_{fm}$        $E_{fs}$

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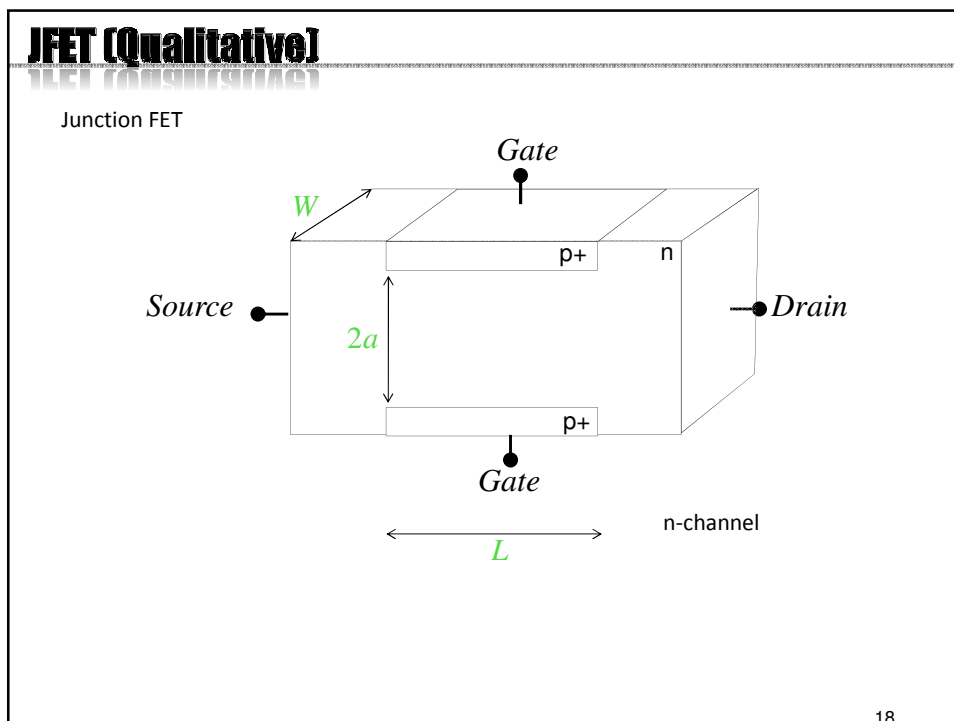


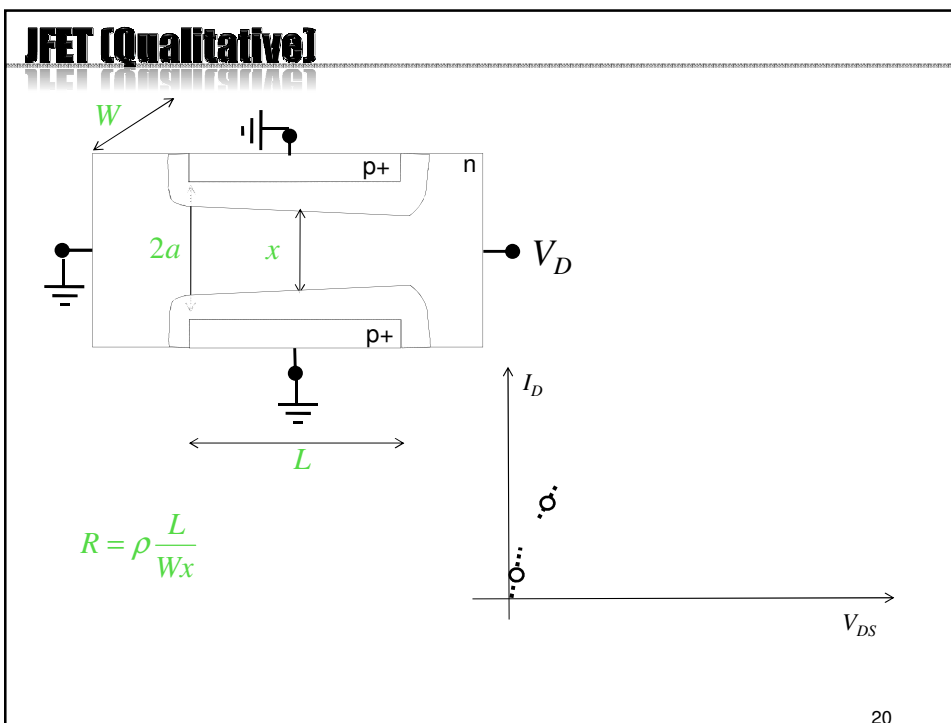
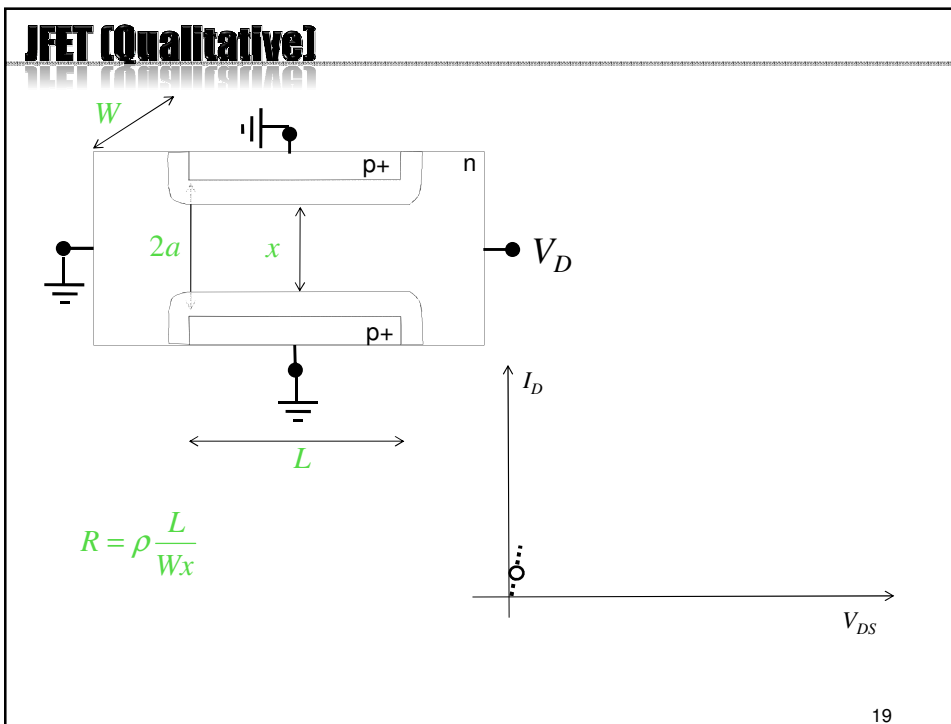


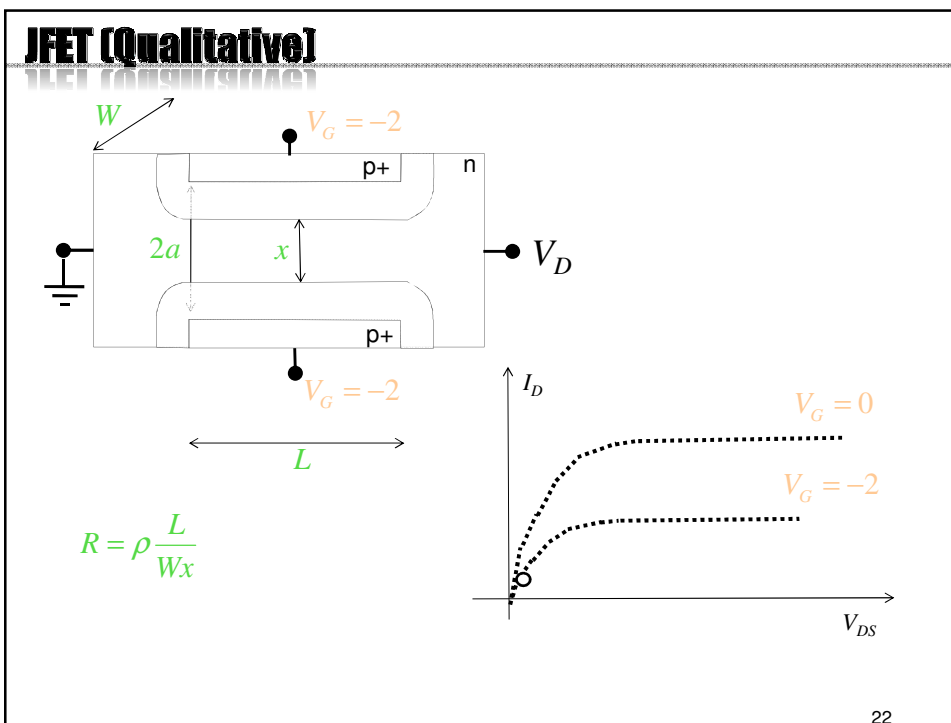
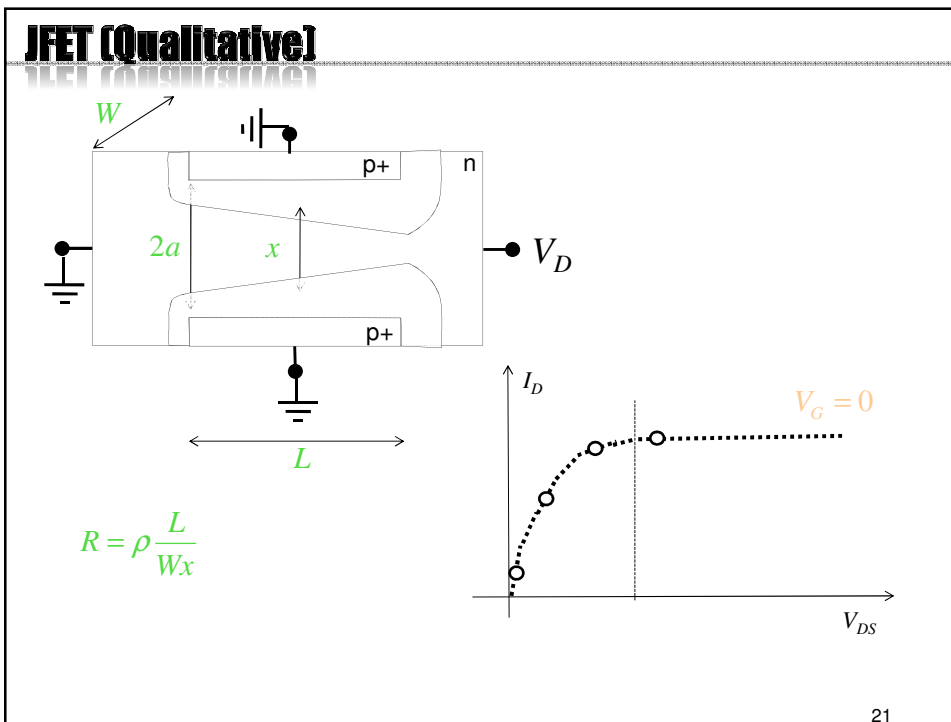
FET: Electrostatics & IV curve

# The Junction FET

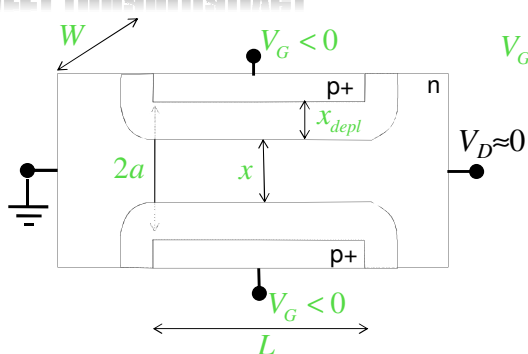
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### JFET (Quantitative)



$$V_G = 0 \rightarrow x_{depl} = \sqrt{\frac{2\epsilon}{qN_D}} \phi_0$$

$$\phi_0 = \frac{kT}{q} \ln\left(\frac{N_A N_D}{n_i^2}\right)$$

$$\phi_0 = \frac{E_G}{2q} + \frac{kT}{q} \ln\left(\frac{N_D}{n_i}\right)$$

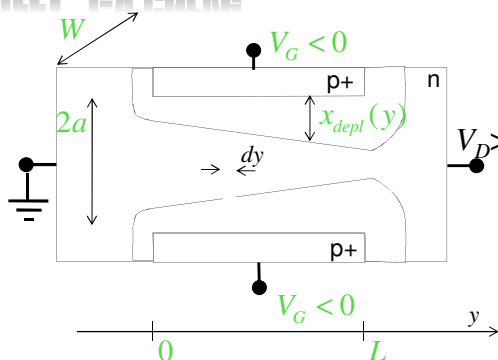
$$x_{depl} = \sqrt{\frac{2\epsilon}{qN_D}} (\phi_0 - V_G)$$

$$\delta I_D = \sigma \frac{A}{L} \delta V_D = q\mu_n N_D \frac{2(a - x_{depl})W}{L} \delta V_D$$

Pinch-off  $x_{depl} = a \rightarrow V_p = \phi_0 - \frac{qN_D a^2}{2\epsilon}$

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### JFET, I-V curve



$$x_{depl} = \sqrt{\frac{2\epsilon}{qN_D}} (\phi_0 - V_G + V(y))$$

B.D.  $V(0) = 0, V(L) = V_D$

$$dR(y) = \frac{1}{q\mu_n N_D} \frac{dy}{2(a - x_{depl}(y))W}$$

$$dV(y) = I_D dR(y)$$

$$dV(y) = \frac{I_D}{q\mu_n N_D} \frac{dy}{2(a - x_{depl}(y))W}$$

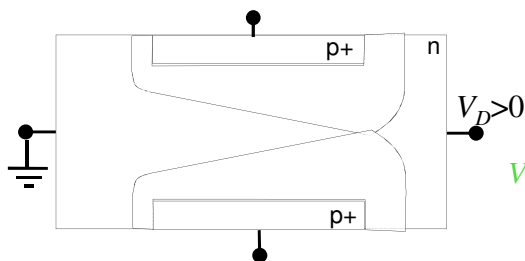
$$2q\mu_n N_D \int_0^{V_D} [a - \sqrt{\frac{2\epsilon}{qN_D}} (\phi_0 - V_G + V(y))] dy = I_D \int_0^L dy = I_D L$$

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### JFET, I-V curve

$$I_D = g_0 \left\{ V_D - \frac{2}{3} \sqrt{\frac{2\epsilon}{qN_D a^2}} \left( (V_D + \phi_0 - V_G)^{3/2} - (\phi_0 - V_G)^{3/2} \right) \right\}$$

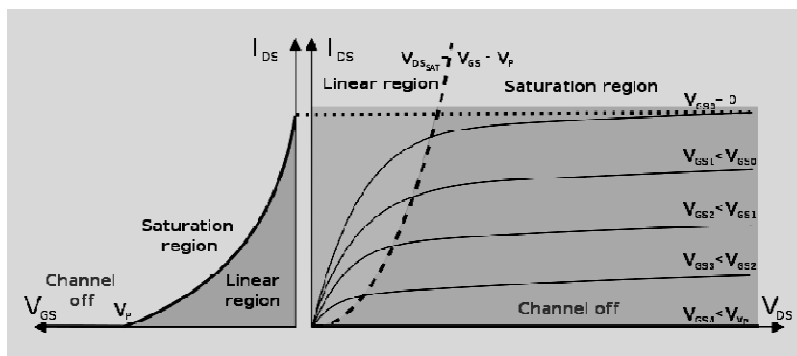
as  $g_0 = 2qN_D a W \mu_n / L$



$$V_{Dsat} = V_G - V_P = V_G - \phi_0 + \frac{qN_D a^2}{2\epsilon}$$

$$I_{Dsat} = I_D |_{V_D=V_{Dsat}} = g_0 \left\{ \frac{qN_D a^2}{6\epsilon} - (\phi_0 - V_G) + \frac{2}{3} \sqrt{\frac{2\epsilon}{qN_D a^2}} (\phi_0 - V_G)^{3/2} \right\}$$

### JFET, I-V curve





Metal Semiconductor FET: Electrostatics & IV curve

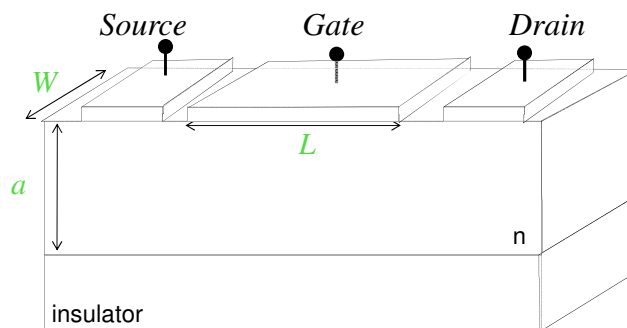
# The MESFET

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## MESFET

MESFET (metal semiconductor field effect transistor)

$f_T > 100\text{GHz}$



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### MESFET (Qualitative)

Source Gate Drain

$V_D = 0 \rightarrow x_{depl} = \sqrt{\frac{2\epsilon}{qN_D}} (V_i - V_G)$

$x_{depl}|_{V_G=V_{Th}} = a \rightarrow V_{Th} = V_i - \frac{qN_D a^2}{2\epsilon}$

$V_D > 0 \rightarrow x_{depl}(y) = \sqrt{\frac{2\epsilon}{qN_D}} (V_i - V_G + V(y))$        $V(0) = 0, V(L) = V_D$

$$dV = I_D dR = I_D \frac{1}{q\mu_n N_D (a - x_{depl}(y))W} dy = \frac{I_D dy}{q\mu_n N_D (a - \sqrt{\frac{2\epsilon}{qN_D}} (V_i - V_G + V(y)))}$$

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### MESFET (Qualitative)

Source Gate Drain

Pinch-off

$I_D = g_0 \left( V_D - \frac{2}{\sqrt{V_p}} \left[ (V_D + V_i - V_G)^{3/2} - (V_i - V_G)^{3/2} \right] \right)$        $g_0 = \frac{1}{L} q\mu_n N_D W$

$V_p = \frac{qN_D a^2}{2\epsilon}$

$V_{Dsat} = V_p - V_i + V_G = V_G - V_{Th}$

$$I_{Dsat} = g_0 \left( \frac{V_p}{3} + \frac{2}{\sqrt[3]{V_p}} (V_i - V_G)^{3/2} - V_i + V_G \right)$$

$$g_m = \left. \frac{\partial I_D}{\partial V_G} \right|_{V_D} = g_0 \left( 1 - \sqrt{\frac{V_i - V_G}{V_p}} \right)$$

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